Notice of Allowability	Application No.	Applicant(s)
	10/616,975	WEI LIU
	Examiner	Art Unit
	leszek b kiliman	1773
The MAILING DATE of this communication appears All claims being allowable, PROSECUTION ON THE MERITS IS herewith (or previously mailed), a Notice of Allowance (PTOL-85) NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT R of the Office or upon petition by the applicant. See 37 CFR 1.313	or other appropriate commu	this application. If not included
1. This communication is responsive to <u>Amendments filed No</u>	ovember 12,2004.	
2. The allowed claim(s) is/are <u>1-18</u> .		
3. The drawings filed on with the application are accepted by	the Examiner.	
4. ☐ Acknowledgment is made of a claim for foreign priority un a) ☐ All b) ☐ Some* c) ☐ None of the: 1. ☐ Certified copies of the priority documents have 2. ☐ Certified copies of the priority documents have 3. ☐ Copies of the certified copies of the priority documents have International Bureau (PCT Rule 17.2(a)). * Certified copies not received: ☐ Applicant has THREE MONTHS FROM THE "MAILING DATE" of noted below. Failure to timely comply will result in ABANDONMETHIS THREE-MONTH PERIOD IS NOT EXTENDABLE. 5. ☐ A SUBSTITUTE OATH OR DECLARATION must be submit INFORMAL PATENT APPLICATION (PTO-152) which gives 6. ☐ CORRECTED DRAWINGS (as "replacement sheets") must (a) ☐ including changes required by the Notice of Draftsperso 1) ☐ hereto or 2) ☐ to Paper No./Mail Date (b) ☐ including changes required by the attached Examiner's Paper No./Mail Date Identifying indicia such as the application number (see 37 CFR 1.8 each sheet. Replacement sheet(s) should be labeled as such in the attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the deposition attached Examiner's comment regarding REQUIREMENT FOR DEPOSIT OF and/or INFORMATION about the	been received. been received in Application cuments have been received of this communication to file a ENT of this application. tted. Note the attached EXAM is reason(s) why the oath or do be submitted. be submitted. on's Patent Drawing Review (Amendment / Comment or in the de header according to 37 CFR and the submitted of	No in this national stage application from the reply complying with the requirements IINER'S AMENDMENT or NOTICE OF eclaration is deficient. PTO-948) attached the Office action of drawings in the front (not the back) of I.121(d).
Attachment(s) 1. ☐ Notice of References Cited (PTO-892)	5. ☐ Notice of Inform	nal Potent Application (DTO, 170)
2. Notice of Draftperson's Patent Drawing Review (PTO-948)	6. Interview Sumr	mal Patent Application (PTO-152)
3. Information Disclosure Statements (PTO-1449 or PTO/SB/08) Paper No./Mail Date		il Date
4. Examiner's Comment Regarding Requirement for Deposit	8. 🛛 Examiner's Sta	tement of Reasons for Allowance
of Biological Material	9.	
Cerro.		

REASONS FOR ALLOWANCE

The following is an examiner's statement of reasons for allowance:

The instant invention claims a semiconductor nanocrystal complex and a method to obtain such nanocrystal complex.

The closest prior art references that relate to the claimed invention are Bawendi'143, '303, '426. Bawendi references teach that it is known in the art to make and use semiconductor nanocrystals. However, the prior art of record does not teach or suggest the instant invention wherein the specific composition and method to obtain semiconductor nanocrystals are claimed.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Any inquiry concerning this communication or earlier communications from the examiner should be directed to leszek b kiliman whose telephone number is 571-272-1509. The examiner can normally be reached on M-T, 6.30-5.00.

The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Art Unit: 1773

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

lk